

Pos.	Substrate	Material	Type of grating	Grating pitch	Line width/ diameter of pillars/ holes	Etch depth	Active area (Diameter)	Defectarea	Unitprice
4 inch									
1	100mm	525µm +- 25µm silicon (100)	linear	150nm	/	not etched yet	95mm	<0,1%	on request
2	100mm	525µm +- 25µm silicon (100)	hex	700nm	/	300nm	95mm	<0,1%	on request
3	100mm	525µm +- 25µm silicon (100)	hex	960nm	/	300nm	95mm	<0,1%	on request
4	100mm	525µm +- 25µm silicon (100)	hex	1800nm	/	300nm	95mm	<0,1%	on request
5	100mm	525µm +- 25µm silicon (100)	hex	2000nm	/	300nm	95mm	<0,1%	on request

Availability of goods is subject to change without further notice



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6 inch									
1	150mm	650µm +- 25µm silicon (100)	linear	300nm	/	not etched yet	140mm	<0,1%	on request
2	150mm	650µm +- 25µm silicon (100)	2d pillar grid	400nm	/	110nm	140mm	<0,1%	on request
3	150mm	650µm +- 25µm silicon (100)	2d pillar grid	450nm	/	150nm	140mm	<0,1%	on request
4	150mm	650µm +- 25µm silicon (100)	linear	500nm	/	not etched yet	140mm	<0,1%	on request
5	150mm	650µm +- 25µm silicon (100)	2d pillar grid	500nm	/	not etched yet	140mm	<0,1%	on request
6	150mm	650µm +- 25µm silicon (100)	2d hole grid	500nm	/	not etched yet	140mm	<0,1%	on request
7	150mm	650µm +- 25µm silicon (100)	linear	800nm	/	not etched yet	140mm	<0,1%	on request
8	150mm	650µm +- 25µm silicon (100)	2d pillar grid	800nm	/	not etched yet	140mm	<0,1%	on request
9	150mm	650µm +- 25µm silicon (100)	2d hole grid	800nm	/	not etched yet	140mm	<0,1%	on request
10	150mm	650µm +- 25µm silicon (100)	2d pillar grid	1000nm	/	not etched yet	140mm	<0,1%	on request
11	150mm	650µm +- 25µm silicon (100)	2d pillar grid	1200nm	/	not etched yet	140mm	<0,1%	on request
12	150mm	650µm +- 25µm silicon (100)	linear	2500nm	/	not etched yet	140mm	<0,1%	on request

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Pos.	Substrate	Material	Type of grating	Grating pitch	Line width/ diameter of pillars/ holes	Etch depth	Active area (Diameter)	Defectarea	Unitprice
8 inch									
1	200mm	725µm +- 50µm silicon (100)	2d pillar grid	500nm	/	105nm 210nm or 315nm	190mm	<0,1%	on request

Request a quotation:

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